Robert J. Seas, Jr. T (202) 663-7907 rseas@sughrue.com

July 11, 2001



BOX PATENT APPLICATION Commissioner for Patents Washington, D.C. 20231

Re:

Application of Taeko IDEGAWA, Atsushi SAWANO, Kousuke DOI, Hidekatsu

KOHARA, and Tsuyoshi NAKAMURA

NOVEL COPOLYMER, PHOTORESIST COMPOSITION, AND PROCESS

FOR FORMING RESIST PATTERN WITH HIGH ASPECT RATIO

Assignee: TOKYO OHKA KOGYO CO., LTD.

Our Reference: Q65210

Dear Sir:

Attached hereto is the application identified above including 45 pages of the specification, including the claims and abstract, two (2) sheets of drawings, executed Assignment and PTO 1595 form, and executed Declaration and Power of Attorney. Also enclosed is the Preliminary Amendment.

The Government filing fee is calculated as follows:

TOTAL FILING FEE
Recordation of Assignment
TOTAL FEE
\$710.00
\$40.00
\$750.00

Checks for the statutory filing fee of \$710.00 and Assignment recordation fee of \$40.00 are attached. You are also directed and authorized to charge or credit any difference or overpayment to Deposit Account No. 19-4880. The Commissioner is hereby authorized to charge any fees under 37 C.F.R. §§ 1.16 and 1.17 and any petitions for extension of time under 37 C.F.R. § 1.136 which may be required during the entire pendency of the application to Deposit Account No. 19-4880. A duplicate copy of this transmittal letter is attached.

Priority is claimed from July 14, 2000, based on Japanese Application No. 2000-214451. The priority document is enclosed herewith.

Respectfully submitted, SUGHRUE, MION, ZINN,

MACPEAK & SEAS, PLLC

Attorneys for Applicant

Robert J. Seas Jr.

Registration No. 21,092